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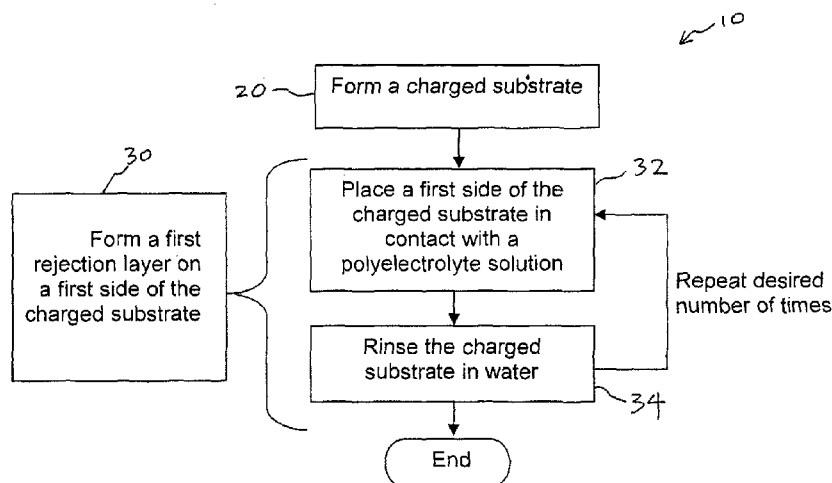
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(54) **Title:** A METHOD OF FORMING FORWARD OSMOSIS MEMBRANES AND THE FORWARD OSMOSIS MEMBRANES THUS FORMED



(57) **Abstract:** There is provided a method of forming forward osmosis (FO) membranes. The FO membrane should have 1) at least one active rejection layer with high water permeability and solute rejection, 2) a support structure or substrate with tailored properties to reduce ICP, and 3) high membrane stability.